



JFW

# TRANSMITTAL OF FORMAL DRAWINGS

Docket No.  
FIS920040102US1

Application Of: **Ramachandran, et al.**

Application No.	Filing Date	Examiner	Customer No.	Group Art Unit	Confirmation No.
10/710,257	06/29/2004	Not yet assigned	32074	2811	4256

Invention: **DUAL-FREQUENCY SILICON NITRIDE FOR SPACER APPLICATION**

Address to:  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Transmitted herewith are:

9 sheets of formal drawing(s) for this application.

☒ Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).

  
Signature

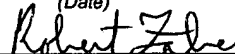
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Dated: **April 25, 2005**

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to "Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450" [37 CFR 1.8(a)] on

**4-26-05**

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Signature of Person Mailing Correspondence

Robert Faber

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